Atomically manipulated proton transfer energizes water oxidation on silicon carbide photoanodes†

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Surmounting the sluggish water oxidation kinetics beyond the hole-dominated thermodynamic effect is a topic of great scientific interest to establish fully renewable hydrogen technology from solar-powered water splitting. Herein, we demonstrate that the bottleneck of photoelectrochemical water oxidation can be overcome via atomic manipulation of proton transfer on the polar surfaces of silicon carbide (SiC) photoanodes. On the typical carbon-face SiC, where proton-coupled electron transfer governed the interfacial hole transfer for water oxidation, substantial energy loss was inevitable due to the highly activated proton-transfer steps. Via preferentially exposing the silicon-face, we enabled surface-catalyzed barrierless O–H breaking with a facile proton exchange and migration character. This mechanistically shifted the rate limiting step of water oxidation from sluggish proton-coupled electron transfer to a more energy-favorable electron transfer. The proof-of-concept study introduced here may open up new possibilities to design sophisticated photoelectrodes for an unbiased solar water splitting cell via surface engineering.

1. Introduction

Solar energy can provide sufficient power to meet the world’s energy demand if it can be efficiently harvested. This is the very reason why photoelectrochemical (PEC) water splitting and CO₂ reduction attract worldwide research interest as a promising sustainable technology for solar fuel production.1–4 The PEC conversion of solar energy into chemical fuels is based on two half-reactions, namely, water oxidation and reduction reactions. The slow-rate oxygen evolution reaction (OER) at photoanodes in many cases is regarded as the bottleneck for PEC reactions, especially when photoanodes are coupled to many metals which can achieve a hydrogen evolution reaction at relatively low overpotentials. This is because the OER involves a four-electron process via several steps with high energy barriers (2H₂O → O₂ + 4H⁺ + 4e⁻).5–6 Despite the large number of methodologies which have been aiming to reduce the OER overpotential, including doping, surface modification, and nanostructure tuning, it still remains a challenge to design a highly active photoanode because the detailed mechanisms of the OER kinetics are still not fully understood.

Intrinsically, it is generally agreed that the OER in a typical PEC reaction is composed of the following four sequential proton-coupled electron transfer (PCET) steps:7–10

\[ \text{H}_2\text{O} \rightarrow \text{OH}^- + \text{H}^+ + e^- \] (1)

\[ \text{OH}^- \rightarrow \text{O}^- + \text{H}^+ + e^- \] (2)

\[ \text{O}^- + \text{H}_2\text{O}(l) \rightarrow \text{OOH}^- + \text{H}^+ + e^- \] (3)

\[ \text{OOH}^- \rightarrow \text{O}_2 + \text{H}^+ + e^- \] (4)

where * denotes the surface adsorbed state, e⁻ is the interfacial electron, H₂O(l) is the liquid water, and H⁺ is the dissociated proton. Among them, the first PCET (*H₂O → *OH⁻ + H⁺ + e⁻), being characterized by both O–H bond breaking associated proton-transfer (PT) and interfacial electron-transfer (ET), is envisioned as the rate-determining step.10 The first PCET of the OER has long been believed to be governed by ET, whose reaction thermodynamics is highly dependent on the redox level of the hole in the valence band (VB) of the photoanode. However, it cannot explain the ineffectiveness of the OER on many pristine semiconductors, including TiO₂, Fe₂O₃ and ZnO, whose VB positions perfectly match with that of water oxidation.11,12 The pioneering work done by Selloni and Liu groups, on the other hand, theoretically demonstrated that beyond the hole-dominated thermodynamic effect, strong kinetic effects concerned with PT were also essential for the OER.10,13–15 For instance, the first PCET was demonstrated to be sequential with PT (*H₂O → *OH⁻ + H⁺) preceding ET (*OH⁻ → *OH + e⁻);
Besides, an inherent high overpotential had arisen from highly activated O–H oxidative cleavage and proton migration within the PT step, rather than the barrierless ET. As a proof of concept, this theory is consistent with the abundant theoretical and experimental findings that thermodynamic hole trapping by water was remarkably enhanced at high pH, when the proton concentration of the electrolyte was low and only deprotonated surface states possessed appreciable energy to trigger the OER, all of which offer a possibility to accelerate the sluggish OER via modifying the delicate PT behavior.16–19

Silicon carbide (SiC) has emerged as a promising semiconductor for photocatalytic applications due to its superior chemical stability, high charge mobility, and suitable energy band positions that straddle the water redox potential.20,21 Most noticeably, SiC is receiving considerable attention as a novel biocompatible material due to its tunable surface chemistry, particularly for the representative polar (carbon or silicon terminated) surfaces, which are commercially available. Depending on the terminated atoms (C or Si), the exposed surfaces display different atomic and electronic structures, which remarkably influence water adsorption, hydroxylation and wet oxidation behaviors. For example, the Si-face of SiC was theoretically proved to be capable of inducing water dissociation towards the formation of surface Si–OH and Si–H fragments, while the C-face displayed “inertness” to afford only molecular water adsorption, as demonstrated by Cicero and Amy et al.22–24 In the light of this, the polar surfaces of SiC have emerged as an ideal platform to manipulate PT behavior for desirable water oxidation and understand more of the details of water oxidation mechanisms. In this study, we theoretically and experimentally demonstrate that the bottleneck of the OER can be overcome via atomic manipulation of PT over the SiC polar surfaces. By preferentially exposing the Si-face, we enabled surface-catalyzed barrierless O–H breaking and proton exchange and migration within the PT step in the first proton removal reaction, which mechanistically shifted the sluggish rate-limiting step on the C-face to a more energy-favorable one, thus making the OER conductive at a very low overpotential even under neutral pH conditions. Mechanistic insights into the challenge of the PT scheme are provided on the basis of detailed theoretical and experimental results.

2. Results and discussion

2.1 Theoretical study of water adsorption on SiC

Density functional theory calculation was first used to model water adsorption and reaction on a prototypical SiC polar surface, the hexagonal 6H–SiC(0001) surface (Fig. 1a). On the C-terminated (0001) surface, H2O was found to remain floating above the surface at low coverage (1/4 ML); even at higher coverage (when two H2O molecules were included into a supercell), water molecules preferred to optimize the internal hydrogen bond (HB) network without interacting with the C-surface (Fig. 1b). The charge density difference revealed an extremely weak HB-like interaction, as reflected by the appearance of charge localization in the region between a surface carbon atom and the –OH group of water. An entirely different picture of water adsorption was found when the Si-terminated (0001) surface was exposed. Irrespective of its initial orientation, H2O would diffuse to a Si–Si dimer, where spontaneous dissociation took place (H2O → OH– + H+) with the –OH fragment bonding to one Si atom, and the –H fragment being transferred to another Si atom (Fig. 1c). Such water dissociation behavior was due to a thermodynamic need to stabilize the dangling bonds and minimize surface energy,23 as evidenced by the significant charge depletion on the Si–Si dimer and charge accumulation on dissociated water fragments with a large adsorption energy of ~3.36 eV (Fig. 1c).

To explore the explicit first shell solvation effect, water adsorption at higher coverage was then modeled. When two H2O molecules were included into a supercell, we observed an interesting synchronous two proton exchange and migration phenomenon. Specifically, besides establishing a Lewis acid-base interaction with the Si surface, H2O(1) formed a reliable HB with a nearby H2O(1), along with H2O(2) dissociation, the –H fragment, that was initially hydrogen-bonded, was transferred to H2O(2) while H2O(1) simultaneously released a –Hb fragment to a neighboring Si atom (Fig. 1d). Besides intermolecular proton exchange, proton exchange with a surface hydroxyl group on the Si-face along with water dissociation was also thermodynamically favorable (Fig. S1a†). This interesting proton exchange and migration behavior remarkably promoted the proton transfer ability (from one Si–Si dimer to another Si–Si dimer) on the Si-terminated surface (Fig. 1d). When three H2O molecules were included into a supercell, two of them preferred to dissociate, while the third one formed a HB network with the two dissociated H2O molecules (Fig. S1b†). The HB network contained two strong HBs and one weak HB, representing a typical intimate interaction between a wetting surface with liquid water (Fig. S1c†). Moreover, the formation of
the HB₃ lengthened the Si–H bond from 1.50 Å to 1.74 Å, simultaneously reducing the barrier of proton transfer to liquid water from 0.85 eV to 0.32 eV. It has to be pointed out that when H₂O was pushed to the C-face at a distance below 1.0 Å, it also dissociated on a C–C dimer. However, water dissociation on the C-face has to overcome a kinetic barrier of 1.41 eV, suggesting that such a reaction would not spontaneously occur even at higher temperature. To estimate the thermodynamics of water oxidation, we calculated the partial density of states (PDOS) of adsorbed water on different exposed surfaces of 6H–SiC. For H₂O weakly bound to the C-face via a HB, its PDOS was deeply embedded in the VB, approximately 2.02 eV lower compared to the VB edge of 6H–SiC, suggesting that hole transfer to the surface adsorbed H₂O was thermodynamically hindered (Fig. 1e). However, dissociated water on the Si-face was apparently more active than molecular water on the C-face towards oxidation, as evidenced by its PDOS that almost overlapped the VB edge (Fig. 1e). This is consistent with the fact that oxidation of OH⁻ to O₂ is thermodynamically more favorable than the oxidation of H₂O to O₂ (Eₒ,OH⁻ = 0.40 V and Eₒ,H₂O = 1.23 V versus the reversible hydrogen electrode).¹⁶

2.2 Experimental study of water adsorption on SiC

The above theoretical scenarios revealed that the Si-face on 6H–SiC not only enabled barrier-less O–H breaking on water adsorption, but also facilitated proton exchange and migration within the PT step, representing a key prerequisite for kinetically improved water oxidation. Meanwhile, from a thermodynamic point of view, water in the dissociated form (OH⁻) with activation energy lower than the oxidation of H₂O to O₂ (Eₒ,H₂O = 1.23 V versus the reversible hydrogen electrode), it was expected that the Si-face would be more active than the C-face towards oxidation. To experimentally verify this calculation results, a mixture of water vapor was exposed to the Si-face and C-face substrates at room temperature (Fig. 2a). The as-grown SiC(000|24) and Si-face 6H–SiC(000|22) substrates were examined by atomic force microscopy (AFM) and X-ray photoelectron spectroscopy (XPS) in situ on an ultrahigh-vacuum system. Fig. 2a shows the surface morphology of the as-grown SiC and Si-face 6H–SiC with different steps. After water adsorption, water was observed on the Si-face and C-face, suggesting that water adsorption on the Si-face was primarily affected by the hydroxyl groups on the Si-face and that such a reaction would not spontaneously occur even at higher temperature. To estimate the thermodynamics of water dissociation (D₂O → OD⁻ + D⁺), the Si-face was consumed. Unexpectedly, concomitant with the OD stretching peak appeared at 2685 cm⁻¹, a new absorption band at 1400 cm⁻¹ was observed on the Si-face before and after water adsorption (Fig. 2c). This is consistent with the fact that the Si-face was more active than the C-face towards water oxidation, as evidenced by its PDOS that almost overlapped the VB edge (Fig. 1e).

2.2.1 Consecutive adsorption study

To explore the possible proton exchange and migration scheme occurring on the Si-face, we further exposed the Si-face, which was pre-hydroxylated with OD, to saturated H₂O vapor. Following a transient water deposition at 298 K, the saturated H₂O vapor in the reaction cell was then gradually re-evacuated with the surface hydroxyl stretching being in situ monitored. Along with evacuation, the broad absorption band ranging from 2700 to 3700 cm⁻¹ and the band at 1628 cm⁻¹, which were respectively assigned to ν(OH) and ν(H₂O), gradually decreased (Fig. 2a). However, IR absorption of ν(OD), which was supposed to remain chemically and thermally stable, experienced a synchronous decrease, suggesting that part of the OD on the Si-face was consumed. Unexpectedly, concomitant with the OD decrease, a new absorption band at 1400 cm⁻¹ gradually appeared, which was indexed to the bending absorption of ν(HDO) (Fig. 2b). Since the IR absorption of ν(HDO) region could maintain high stability under even higher vacuum, the as-formed HDO was believed to reside in the wetting layer, which interacted strongly with the hydroxyl groups on the Si-face via HBs (–Si–OH···HDO). Moreover, the almost linear decrease of ν(OD) and increase of ν(HDO) along with evacuation time suggested that the consumption of OD on the Si-face was directly associated with HDO generation (Fig. 2b). Conceivably, facile proton exchange and migration between OD on the Si-face and outer layer H₂O was supposed to dominate this process (–Si–OD + H₂O → –Si–OH···HDO) (Fig. S4a†).

In order to more precisely specify the components in the above water film on the Si-face, electron-stimulated and photon-stimulated desorption (ESD and PSD) techniques were carried out (Fig. 2c). In order to prepare a thin water film with a possible proton exchange layer on 6H–SiC, D₂O was first deposited on SiC to ensure OD hydroxylation, followed by evacuation (Fig. 2d). Then, 2–3 ML H₂O was deposited on the hydroxylated 6H–SiC surfaces to enable the formation of a hybrid thin water film (Fig. 2d). Upon re-evacuation, H₂O was observed on the Si-face of 6H–SiC, we were able to observe an abrupt H₂O signal increase when the electron beam was turned on, followed by a rapid decay, indicating that stimulated H₂O desorption directly happened on the water/vacuum interface (Fig. 2e). Besides, another signal corresponding to the proton exchange product of HDO was vividly witnessed on the Si-face, as depicted by a promotive increase but remarkably slower decrease (Fig. 2e). It is to be noted that an induction period appeared during stimulated HDO desorption. This is because electron-stimulated HDO desorption would occur only when the outer-layer H₂O was largely desorbed (Fig. S4b†), confirming that the proton exchange and migration region was located at the water/6H–SiC interface. As for the C-face, it displayed an appreciably lower H₂O desorption and no observable signal of HDO, in agreement with its poor affinity to water as will be shown below. We also considered the effect of
light (λ < 400 nm) illumination on the desorption manners of other related molecules, including H2 and HD. After the light was turned on, we successfully observed the desorption of H2 from the Si-face or C-face, arising from water splitting, which was pronounced, but sluggish, as it was saturated only after 40 s (Fig. 2f). Interestingly, another signal indexed to the proton exchange product of HD was perceived on the Si-face but was not observed on the C-face. Moreover, in stark contrast to the H2 signal, the HD signal increased more abruptly on the Si-face, reaching a maximum within 10 s (Fig. 2f). Since photon-induced water splitting preferentially occurred at the 6H–SiC/water interface (Fig. S4c†), the pronounced HD signal, derived from interfacial HDO, indicated facile proton exchange and migration on the Si-face of 6H–SiC was exceedingly beneficial for overall water splitting.

The macroscopic water–SiC interaction was also studied by water contact angle measurement. The C-face was found to be hydrophobic with a large contact angle of 95.8°, consistent with the weak molecular water adsorption behavior on this face (Fig. 3a). Differently, the water contact angle on the Si-face was only 36.7°, showing that the interaction between water and the Si-face should be much stronger (Fig. 3b). This peculiar hydrophilic character of the Si-face could be explained by the facile proton exchange and migration, as well as the strong HB network constructed between the inner and the outer layer of water, which facilitated the overall water adsorption.14,26 Enlightened by the above experimental results, we further prepared Si- and C-face 6H–SiC photoanodes. A 200 nm thick Al layer was deposited on the backside of the highly conductive 6H–SiC films (0.8 cm × 0.8 cm) for making an ohmic contact for both the Si- and C-face 6H–SiC photoanodes, as evidenced by the linear I–V curve (Fig. 3c and S5†). A three-electrode photoelectrochemical cell was used to evaluate the PEC performances of the C- and Si-face 6H–SiC photoanodes in 0.5 M pH 6.8 Na2SO4 solution. Both 6H–SiC faces showed a low dark current in the linear sweep voltammetry scan, suggesting the absence of any chemical reactions in the dark. Under monochromatic light (λ = 410 nm, I0 = 30 mW cm−2), even though the C-face 6H–SiC photoanode exhibited a low onset-potential of 0.15 V versus the...
reversible hydrogen electrode (RHE) in the $J-V$ curve, a remarkable current increase occurred only from 0.56 V, suggesting a typical sluggish water oxidation behavior due to the robust electron/hole recombination (Fig. 3d). As for the 6H–SiC photoanode with the Si-face, the onset potential of water oxidation is 0 V versus RHE even under neutral conditions, indicating that the OER can occur without external bias. Besides, a precipitous photocurrent increase occurred at as low as 0.10 V, which is a 0.46 V cathodic shift relative to the 6H–SiC photoanode with the C-face (Fig. 3d). Moreover, a plateau appeared around 0.40 V over the Si-face with a saturated photocurrent density of 1.01 mA cm$^{-2}$, which is limited to the light intensity. It is noteworthy that to reach the plateau of photocurrent density, C-face 6H–SiC required a bias as large as 1.50 V.

2.3 Photoelectrochemical performance of SiC photoanodes

The remarkably reduced energy for triggering the OER on the Si-face could also be reflected in the applied bias photon-to-current efficiency (ABPE) in a two-electrode system. The maximum ABPE of 16.7% was achieved at an extremely low bias of 0.08 V on the Si-face under 410 nm monochromatic light, while it required a higher applied bias of 0.45 V to reach a comparable ABPE on the C-face (Fig. 4a). Correspondingly, the Si-face exhibited an obviously higher incident photo-to-current conversion efficiency than the C-face in the wavelength region of 300–410 nm (above the bandgap of 6H–SiC, 3.0 eV), even though they possessed almost the same light absorption capacity and identical optical band-edge absorption (Fig. S6†).

Moreover, online O$_2$ detection via gas chromatography (GC) confirmed that the photon-to-current conversion was mainly associated with stable O$_2$ production with a current-to-O$_2$ efficiency exceeding 90% under a bias of 0.4 V$_{RHE}$ in a three-electrode system (Fig. 4b). Since both the C- and Si-face 6H–SiC films possessed identical doping concentrations and comparable Fermi levels (Fig. S7†), we believe the onset potential, the photocurrent density and the evolved O$_2$ differences over the photoanode with different faces are more related to surface charge kinetics rather than the flat band potential, conductivity, or bulk recombination. To prove this point of view, we quantitatively determined the quantum efficiency ($\phi_{ox}$) of water oxidation by surface holes according to the method developed by Dotan et al. The photocurrent density ($J$) arising from the OER is theoretically described as $J = J_{abs}\phi_{sep}\phi_{ox}$, where $J_{abs}$ is the theoretical photocurrent density of 6H–SiC assuming the absorbed photon conversion efficiency to be 100%, and $\phi_{sep}$ represents the charge separation yield of the photogenerated carriers (Fig. S8†). For an easily oxidized surrogate substrate like H$_2$O$_2$, surface recombination is completely suppressed with $\phi_{ox} = 1$. Therefore, when probing water oxidation using the same photoelectrode, $\phi_{ox}$ can be calculated from the ratio of $J$(H$_2$O)/$J$(H$_2$O)$_2$. To obtain $J$(H$_2$O)$_2$, we performed linear sweep voltammetry over the photoanodes in the presence of 0.1 M H$_2$O$_2$ under the same conditions. Interestingly, the $J-V$ curve of the 6H–SiC photoanode with the C-face performing H$_2$O$_2$ oxidation experienced a remarkable cathodic shift and sharp rise, resembling that of the 6H–SiC photoanode with the Si-face performing water oxidation (Fig. 4c). The calculated $\phi_{ox}$ of the C-face in our case was very low at a bias below 0.6 V, reaching 80% at a higher bias of 1.0 V (Fig. 4d). As for the Si-face, it maintained a high $\phi_{ox}$ approaching unity throughout the whole applied bias region (Fig. 4d). This demonstrated that separated holes on the Si-face more vividly participated in the surface water oxidation towards PEC oxygen evolution (Fig. 4d).

2.4 Photoelectrochemical water oxidation kinetics on SiC photoanodes

Apparently, the reason why the Si-face of 6H–SiC displayed lower charge recombination kinetics and stronger reaction kinetics for water oxidation than the C-face was closely related to its specific atomic structure. According to our theoretical and experimental results, the unique water dissociation mode on the Si-face of 6H–SiC with a facile proton exchange and migration character within the PT step was hypothesized to contribute substantially to its superior OER performance. To gain deep insight into the peculiar PT possibly occurring on the Si-face of the 6H–SiC photoanode, we first evaluated the surface charge transfer kinetics via monitoring the photocurrent transient change under a progressively increasing bias. The transient photocurrent of the C-face photoanode showed a large spike in the initial stage at either low or high applied potential, followed by a multiexponential decrease due to the charge carrier recombination (Fig. 5a).

According to the work by Zhong and Zhang et al., such photocurrent decaying shape represented a characteristic OER
kinetic sluggishness due to the limited PT to water solvent or the catalytic surface during PCET steps. Typically, this major kinetic inadequacy could be circumvented in basic electrolytes, because OH\textsuperscript− was easier to oxidize than H\textsubscript{2}O. As expected, the spikes were suppressed in 0.1 M NaOH, suggesting the suppression of surface recombination when kinetic PT was no longer involved (Fig. 5a and b). In contrast, the photocurrent response over the Si-face was not only substantially higher even under neutral conditions than the C-face, but also showed higher stability, as characterized by the small spikes at low bias and square shape of chopped photocurrent at high bias (Fig. 5b). This observation suggested that PT was no longer a kinetic bottleneck on the Si-face 6H-SiC photoanode in a neutral electrolyte. To acquire quantitative kinetic information on PT during the OER, the H/D isotopic labelling experiment was carried out. The steady-state photocurrent from the J–t curves after 120 s of irradiation was used to calculate the kinetic isotopic effect (KIE) in H\textsubscript{2}O and D\textsubscript{2}O (KIE = J(H\textsubscript{2}O)/J(D\textsubscript{2}O)) at different pH values. At a given moderate potential of 0.4 V\textsubscript{RHE}, pronounced KIE values over 2.0 were witnessed on the C-face at low pH (7–9) (Fig. 5c). These characteristic KIE values indicated that oxidation of water in the molecular state was the dominant reaction with O–H bond cleavage serving as the rate determining factor in the PCET steps of the OER. A similar mechanism was observed in biological and artificial molecular water oxidation systems. At higher pH (10–13), KIE values gradually decreased and became unity around 13, suggesting that the oxidation of OH\textsuperscript− governed by ET was the major reaction. Differently, the Si-face photoanode exhibited a small KIE at either low pH or high pH, suggesting that the dominant step during the OER was ET. Moreover, we calculated the KIE values from the ratio of the evolved O\textsubscript{2} gas under neutral or alkaline conditions (KIE = O\textsubscript{2}(H\textsubscript{2}O)/O\textsubscript{2}(D\textsubscript{2}O) or O\textsubscript{2}(NaOH)/O\textsubscript{2}(NaOD)). Consistently, the Si-face photoanode exhibited distinct low KIE values around 1.2 under either neutral (D\textsubscript{2}O) or alkaline (OD\textsuperscript−, pH 12) electrolytes (Fig. 5d). Meanwhile, even under stronger near UV light irradiation (>80 mW cm\textsuperscript{−2}), the Si-face photoanode was still able to maintain low KIE values towards the OER. This directly confirmed our theoretical prediction that on the Si-face of 6H-SiC, surface-catalyzed O–H breaking on water adsorption towards the formation of OH\textsuperscript− was a barrierless process, which also promoted proton exchange and migration within PT during the OER, thus suppressing surface charge recombination in case of PCET and enhancing overall OER kinetics (Fig. 5e).

2.5 Construction of the zero-biased photoelectrochemical system

The ultimate goal for practical PEC device designing is to construct an operative two-electrode system for overall water
splitting without any external bias (Fig. 6a), which is denoted as zero-biased water splitting. The 6H–SiC photoanode, a competitive material to enable such a conceptual design, is a near-UV-light responsive semiconductor that largely limits its sufficient absorption to visible light. However, this proof-of-concept PT manipulation strategy we have explored over 6H–SiC can be perfectly applied to cubic 3C–SiC, a more ideal polymorph of SiC for PEC application due to its electronic structure. As compared with 6H–SiC, 3C–SiC possesses an extended absorption edge around 500 nm and a suitable bandgap around 2.3 eV, which ensures ample solar light absorption, while simultaneously maintaining high potentials of the photogenerated charge carriers for water splitting reactions (Fig. 6b and c). Transparent Si-face of 3C–SiC demonstrated that water was preferentially dissociated on the Si-face. The understanding gained in this study unravels the vital role that PT plays in determining the kinetics of water oxidation. In conclusion, using switchable polar SiC surfaces as the platform, we demonstrated that the bottleneck of water oxidation could be overcome via manipulating PT at the surface molecular level. On the C-face of SiC, where PCET governed the interfacial hole transfer for water oxidation, substantial energy loss was inevitable due to the PT steps. Via preferentially exposing the Si-face, we enabled surface-catalyzed barrier-less O–H breaking, with a facile proton exchange and migration character. This mechanistically shifted the rate limiting step of water oxidation from sluggish PCET on the C-face to a more energy-favorable ET on the Si-face. The understanding gained in this study unravels the vital role that PT plays in determining the kinetics of water oxidation and may open up new possibilities for the design of sophisticated photoelectrodes and zero-biased PEC systems via surface engineering.

3. Conclusions

In conclusion, using switchable polar SiC surfaces as the platform, we demonstrated that the bottleneck of water oxidation could be overcome via manipulating PT at the surface molecular level. On the C-face of SiC, where PCET governed the interfacial hole transfer for water oxidation, substantial energy loss was inevitable due to the PT steps. Via preferentially exposing the Si-face, we enabled surface-catalyzed barrier-less O–H breaking, with a facile proton exchange and migration character. This mechanistically shifted the rate limiting step of water oxidation from sluggish PCET on the C-face to a more energy-favorable ET on the Si-face. The understanding gained in this study unravels the vital role that PT plays in determining the kinetics of water oxidation and may open up new possibilities for the design of sophisticated photoelectrodes and zero-biased PEC systems via surface engineering.

4. Experimental section

4.1 Preparation of 6H–SiC(0001) films and photoanodes

The Si- and C-face 6H–SiC epilayers were grown by CVD on highly n-type doped Si- and C-face 4-degree-off-axis 6H–SiC substrates, respectively. The thicknesses for both epilayers are around 30 μm. The Mott–Schottky measurements show an identical n-type doping concentration of 1.5 × 10\(^{15}\) cm\(^{-3}\) for both Si- and C-face 6H–SiC epilayers. Prior to the deposition of ohmic contacts on the backside of the films, they were chemically cleaned with acetone, ethanol, H\(_2\)O : NH\(_3\) : H\(_2\)O\(_2\) (5 : 1 : 1), H\(_2\)O : HCl : H\(_2\)O\(_2\) (6 : 1 : 1), hydrofluoric acid (HF) and water. The samples were then fixed on a sample holder and placed inside a vacuum chamber together with an aluminum (Al) source for evaporation. The vacuum chamber was connected to a device calibrated for metal evaporation within the system such that desired thicknesses could be input and applied power for the evaporation is set automatically. The resulting contacts were made of a 200 nm layer of Al on the backside of the samples to ensure good ohmic behaviors, as seen in Fig. S5. The samples with deposited contacts on their backside could be made into working electrodes by gluing them onto a piece of glass using copper tape. On some samples silver paste was used to further secure good contact between the copper and semiconducting. The whole electrode was then covered in epoxy resin, apart from...
the front surface of the semiconductor, which is supposed to be in contact with the electrolyte.

4.2 Preparation of 3C–SiC(111) films

Bulk-like off-axis 3C–SiC(111) samples with a thickness of ~1 mm were grown on 4 degree off-axis 4H–SiC substrates (SiCrystal) by the sublimation epitaxial growth technique.\textsuperscript{44,45} Then 300–400 μm thick free-standing 3C–SiC layers were obtained by polishing away the 4H–SiC substrates and the interfacial layer. To remove contaminants and oxide from the surface, the 3C–SiC substrates were chemically cleaned using acetone, ethanol, H2O : NH3 : H2O2 (5 : 1 : 1), H2O : HCl : H2O2 (6 : 1 : 1), hydrofluoric acid (HF) and water. For making ohmic contact, 200 nm aluminum was deposited on the backside of each 3C–SiC sample by similar thermal evaporation.

4.3 Materials characterization

A Nicolet iS50FT-IR spectrometer was used to \textit{in situ} record diffuse reflectance FTIR spectra on SiC. A contact angle goniometer (OCA-20, DataPhysics, Germany) was adopted to measure the water contact angles on SiC surfaces. The phase structure of SiC was studied by powder X-ray diffraction (XRD) on a Rigaku D/MAX-RB diffractometer. Photo-generated O2 and H2 were detected using a GC equipped with a mass spectrometer (Trace 1300-ISQ, Thermo). The surface topography of SiC was characterized with a 5 × 5 μm² area using an atomic force microscope (AFM) in tapping mode. Electron-stimulated desorption (ESD) was carried out in an ultrahigh vacuum chamber (3 × 10⁻¹¹ mbar), equipped with a low-energy electron gun (100 eV), a mass spectrometer and a molecular beam for water (H2O/D2O) deposition on the SiC substrate. Each individual scan on the SiC substrate was performed for 1 s, delivering a fluence around 3 × 10¹¹ e⁻ per cm². For photon-stimulated desorption (PSD) measurement, an Hg lamp with a 400 nm short-pass filter (~400 nm light was cut off) was used that did not remarkably influence the temperature of the SiC substrate.

4.4 PEC measurement

The PEC setup consisted of a cell with a quartz window on its side and a lid with several holder positions for electrodes. Unless otherwise stated, 0.5 M Na2SO4 solution of pH 6.8 was used as the electrolyte and 410 nm monochromatic light was used as the light source. Through the lid the electrodes were placed, the working electrode facing the quartz window, and the counter and reference electrodes close by. A Pt electrode was used as the counter and the Ag/AgCl was used as the reference electrode. F–V curves were measured using a scan rate of 10 mV s⁻¹ and RHE was calculated using the Nernstian relation \( V_{\text{RHE}} = V_{\text{Ag/AgCl}} + 0.0591 \, \text{pH} + 0.1976 \, \text{V} \). Before the measurement, the electrolyte was purged with Ar for 0.5 h to remove the dissolved O₂. For the isotopic labelling experiment, D₂O was used as the solvent and NaOD was used to adjust the pH of the electrolyte. To determine the ABPE, a two-electrode system (working electrode and counter electrode) was used. The solar conversion efficiency of PEC water oxidation was also evaluated using ABPE in a strict two electrode system according to the following equation:

\[
\text{ABPE} = \left( \frac{I_{\text{ph}}}{P_{\text{total}}} \right) \times (1.23 - |V_{\text{bi}}|) \left( \frac{\text{mW}}{\text{cm}^2} \right)
\]

where \( I_{\text{ph}} \) is the photocurrent density obtained under an applied bias \( V_{\text{bi}} \) between the SiC electrode and the Pt counter electrode, 1.23 V is the standard water splitting reaction potential and \( P_{\text{total}} \) is the incident light intensity of 410 nm monochromatic light (30 mW cm⁻²).

4.5 Theoretical calculations

All the above calculations were performed using the first-principles density functional theory (DFT) + U calculations with the exchange–correlation energy functional, which were described by the generalized gradient approximation with the Perdew–Burke–Ernzerhof (PBE) exchange–correlation functional.\textsuperscript{46} The project augmented wave (PAW) method was applied to describe electron–ion interactions with a plane-wave cutoff energy of 400 eV.\textsuperscript{47,48} In our simulations, the \( 2 \times 2 \) supercells with a vacuum thickness of 20 Å were built for Si- and C-terminated SiC surfaces, respectively. For optimization calculations, the energy and force converged to \( 10^{-5} \) eV per atom and 0.02 eVÅ⁻¹. A Monkhorst–Pack mesh was assigned as \( 5 \times 3 \times 1 \).\textsuperscript{49} Transition states were determined by the nudged elastic band (NEB) method.\textsuperscript{50,51} The interaction energy of the adsorbate water on the SiC surface was calculated as: \( \Delta E = E(\text{H}_2\text{O}/\text{SiC}) - E(\text{SiC}) - E(\text{H}_2\text{O}) \). \( E(\text{H}_2\text{O}/\text{SiC}) \) is the total energy of the water adsorbed SiC system. \( E(\text{SiC}) \) and \( E(\text{H}_2\text{O}) \) are the energies of isolated SiC and H2O respectively. The charge density difference was calculated as: \( \Delta \rho = \rho(\text{H}_2\text{O}/\text{SiC}) - \rho(\text{H}_2\text{O}) - \rho(\text{SiC}) \). \( \rho(\text{H}_2\text{O}/\text{SiC}) \) is the density of the water adsorbed SiC system. \( \rho(\text{H}_2\text{O}) \) and \( \rho(\text{SiC}) \) are the densities of the two isolated subsystems.

Conflicts of interest

There are no conflicts to declare.

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Notes and references
